

Non-local optical response in silver-silicon-silver heterostructure system

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INTRODUCTION

Surface plasmon polaritons (SPP) in a thin metal film has been studied extensively in recent years due to their unique properties such as a huge increase of intensity [1], non-locality [2], etc. Recently, Trolle et al. [4] suggested a mechanism of optical excitation in silicon with photon energy below the direct bandgap using the non-locality of SPP in a silver thin film embedded in crystalline silicon. With a quantum mechanical point of view, this can be explained by the uncertainty principle, which asserts a wider spread

of uncertainty in momentum space with high confinement in spatial space. In this abstract, we examine the indirect optical absorption in a silicon nanowire coupled with silver nanocavity.

ELECTRIC FIELD IN AG-SI-AG HETEROSTRUCTURE

In this abstract, we perform a one dimensional analysis to calculate the optical power absorption rate in the structure shown in Figure 1. By solving the 2D wave equation assuming $\mathbf{E}(\mathbf{r}, t) = E(\mathbf{r})e^{i\omega t}$, we get

$$E_x(z) = \begin{cases} -iA \frac{s_1}{\omega \epsilon_1 \epsilon_0} e^{-s_1 z} e^{i\beta x} & z > h/2 \\ i \frac{A}{2} \frac{1}{\omega \epsilon_0} \left[\left(\frac{s_2}{\epsilon_2} - \frac{s_1}{\epsilon_1} \right) e^{(-s_1 - s_2)h/2} e^{s_2 z} - \left(\frac{s_2}{\epsilon_2} + \frac{s_1}{\epsilon_1} \right) e^{(-s_1 + s_2)h/2} e^{-s_2 z} \right] e^{i\beta x} & -h/2 < z < h/2 \\ i \frac{A}{2} \frac{1}{\omega \epsilon_0} \frac{s_1 \epsilon_2}{s_2 \epsilon_1} \left[\left(\frac{s_2}{\epsilon_2} - \frac{s_1}{\epsilon_1} \right) e^{-s_2 h} - \left(\frac{s_2}{\epsilon_2} + \frac{s_1}{\epsilon_1} \right) e^{s_2 h} \right] e^{s_1 z} e^{i\beta x} & z < -h/2 \end{cases} \quad (1)$$

and

$$E_z(z) = \begin{cases} -A \frac{\beta}{\omega \epsilon_1 \epsilon_0} e^{-s_1 z} e^{i\beta x} & z > h/2 \\ -\frac{A}{2} \frac{1}{\omega \epsilon_0} \frac{\beta}{s_2} \left[\left(\frac{s_2}{\epsilon_2} - \frac{s_1}{\epsilon_1} \right) e^{(-s_1 - s_2)h/2} e^{s_2 z} + \left(\frac{s_2}{\epsilon_2} + \frac{s_1}{\epsilon_1} \right) e^{(-s_1 + s_2)h/2} e^{-s_2 z} \right] e^{i\beta x} & -h/2 < z < h/2 \\ -\frac{A}{2} \frac{\beta}{\omega \epsilon_0} \frac{\epsilon_2}{s_2 \epsilon_1} \left[\left(\frac{s_2}{\epsilon_2} - \frac{s_1}{\epsilon_1} \right) e^{-s_2 h} - \left(\frac{s_2}{\epsilon_2} + \frac{s_1}{\epsilon_1} \right) e^{s_2 h} \right] e^{s_1 z} e^{i\beta x} & z < -h/2 \end{cases} \quad (2)$$

where A is incident field intensity, s_i and β decay constants, ϵ_i dielectric functions, and ω the energy. With appropriate boundary conditions in each region, we get a dispersion relation

$$s_i^2 = \beta^2 - k_0^2 \epsilon_i \quad (i = 1, 2), \quad (3)$$

and the continuity of E_x at $z = -h/2$ gives the dispersion equation

$$s_2 \epsilon_1 - s_1 \epsilon_2 e^{s_1 h} = 0 \quad (4)$$

which has to be satisfied in order for solutions to exist. The equations (3) and (4) are solved numerically. The frequency- and wavevector- dependent dielectric function of silicon, ϵ_2 , is obtained empirically using time-dependent density functional theory [5], and the dielectric function of silver, ϵ_1 , is calculated using Drude-Lorentz model. [6]

The time-averaged optical power absorption rate is given by

$$P_{abs} = \frac{\omega}{2} \int \mathbf{P}(\mathbf{r}, \omega) \cdot \mathbf{E}^*(\mathbf{r}, \omega) d\mathbf{r} \quad (5)$$

where the polarization density, \mathbf{P} , is given by $\mathbf{P}(\mathbf{r}, \omega) = \epsilon_0 \tilde{\chi} \mathbf{E}(\mathbf{r}, \omega)$. The non-local optical power absorption can be computed by Fourier-transforming the equation (5) to get the sum of contributions of SPP over the momentum space.

RESULTS AND DISCUSSION

The non-local optical power absorption in silicon and silver are plotted in Figures (2) and (3), respectively. In silicon, several distinct peaks are appeared at $\hbar\omega = 1.4$ eV, 2.35 eV, 2.5 eV, and 2.7 eV. These results overlap well with our previous calculation of the local density of states of plasmons in silver

[7], and also with an experiment of hot luminescence from a similar structure. [8]

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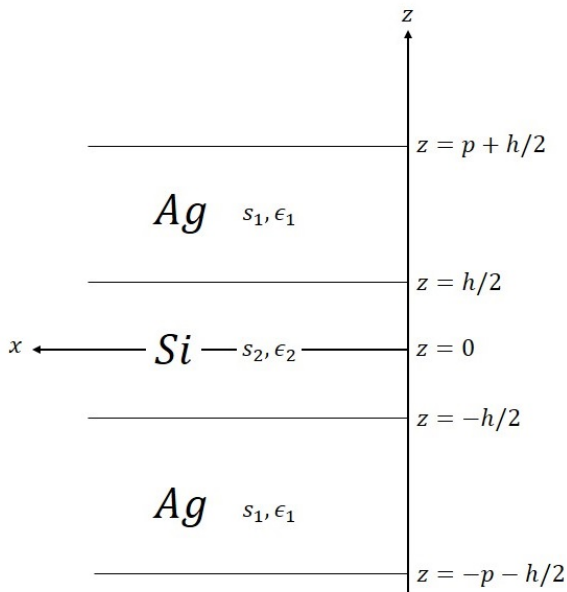


Fig. 1: Si-Ag-Si heterostructure

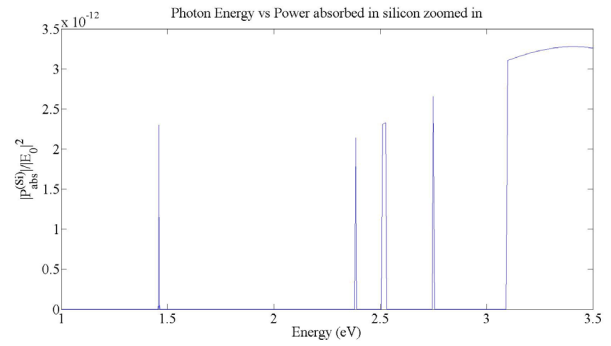


Fig. 2: Power absorption rate in silicon nanowire vs energy of photon

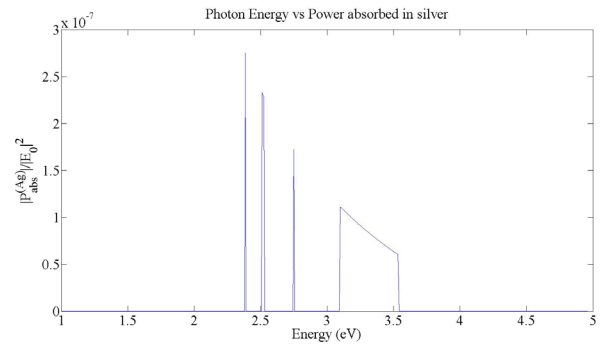


Fig. 3: Power absorption rate in silver vs energy of photon